



**NATIONAL TECHNICAL UNIVERSITY OF ATHENS**  
**SCHOOL OF CHEMICAL ENGINEERING**  
**DEPARTMENT OF PROCESS ANALYSIS & PLANT DESIGN**

**PhD Thesis Defense Announcement**

**Georgios P. Gakis**

Dipl. Chem. Eng.

will defend his PhD Thesis, entitled

***Multiscale modelling and experimental analysis of atomic layer deposition (ALD) of alumina:  
Interplay of process dynamics, chemistry and interfacial phenomena***

Wednesday, 30 October 2019, 14:00

**Multimedia Auditorium, Central Library Building, Zografou Campus**

The Examination Committee:

A.G. Boudouvis, Professor, School of Chemical Engineering, NTUA, Greece, Co-Supervisor

B. Caussat, Professor, INP Toulouse, France, Co-Supervisor

Dr. E. Blanquet, Research Director, Grenoble Institute of Technology, France, Rapporteur

Dr. A. Dimoulas, Research Director, NCSR "Demokritos", Greece, Rapporteur

Dr. E. Scheid, Researcher, CNRS-LAAS, Toulouse, France

E. Pavlatou, Professor, School of Chemical Engineering, NTUA, Greece

A. Papathanasiou, Assoc. Professor, School of Chemical Engineering, NTUA, Greece

Dr. A. Turgambaeva, Researcher, Nikolaev Institute of Inorganic Chemistry, Russia

Invited:

Dr. C. Vahlas, Research Director, CNRS & CIRIMAT Toulouse, France

Dr. H. Vergnes, INP Toulouse, France